

(19)



Europäisches Patentamt
European Patent Office
Office européen des brevets



(11)

EP 0 962 036 B1

(12)

EUROPEAN PATENT SPECIFICATION

(45) Date of publication and mention
of the grant of the patent:
13.03.2002 Bulletin 2002/11

(51) Int Cl.7: **H01S 3/094**, H01S 3/06,
H01S 3/042

(21) Application number: **98962958.9**

(86) International application number:
PCT/US98/26003

(22) Date of filing: **08.12.1998**

(87) International publication number:
WO 99/33151 (01.07.1999 Gazette 1999/26)

(54) **Laser apparatus with integral pump-light concentrator**

Laservorrichtung mit integralem Pumplicht-Konzentrator

Dispositif laser avec concentrateur de lumière de pompage intégré

(84) Designated Contracting States:
DE FR GB

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(43) Date of publication of application:
08.12.1999 Bulletin 1999/49

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(56) References cited:
EP-A- 0 801 449 **US-A- 5 349 600**

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USA, vol. 35, no. 15, pages 2562-2565,
XP000589855 ISSN 0003-6935**

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Description

TECHNICAL FIELD

5 **[0001]** The present invention relates generally to the field of lasers and more particularly to a laser pump cavity apparatus with integral pump light concentrator.

BACKGROUND

10 **[0002]** In integrating laser pump cavities, the pump light is reflected more than once. Thus, pump absorption is superimposed during several passes through the slab. In integrated laser pump cavity devices with an integral concentrator the doped laser crystal and the concentrator are typically both made of the same crystal type. The doped laser crystal and the undoped concentrator are generally made using diffusion bonding technology which is well known in the industry. Diffusion bonding technology produces a bond that is as strong as the host crystal and provides a good
15 optical, mechanical and thermal interface. Conventional diffusion bonding is performed on crystals of similar type.

[0003] Diffusion bonding of dissimilar crystal types has recently been developed by Onyx Optics under a Phase I Small Business Innovative Research (SBIR) grant, funded by the U.S. government. Specifically, a 4mm by 4mm interface between yttrium aluminum garnet (YAG) and sapphire (Al_2O_3) was formed by the Onyx Optics diffusion bonding process that exhibited low stress birefringence ($<10\text{nm}/\mu\text{m}$ wavefront retardation) without fine annealing, high bond
20 strength (600 Mpa-equivalent to bulk YAG), and high thermal shock resistance. The proposed uses to date do not include high power solid-state laser pump cavities with integral concentrators.

SUMMARY

25 **[0004]** The pump cavity of the present invention is a form of integrating pump cavity made of a high aspect ratio slab of solid-state laser material that is uniformly and efficiently pumped with laser diode arrays in directions transverse to the laser beam axis. In this invention the diffusion bonded cladding layer is preferably of dissimilar crystal type than the doped laser crystal active region.

[0005] The present invention as defined in claim 1 is a laser pump cavity apparatus with integral concentrator which
30 has a doped laser crystal active lasing region, a concentrator having at least top and bottom layers which are made of a crystal material different from the doped laser crystal used to form the active laser region and preferably with lower index of refraction, higher thermal conductivity and higher stress fracture strength. The concentrator includes a top cladding layer formed on a top surface of the doped laser crystal with an upwardly facing substantially cylindrical concave outer surface, and a bottom cladding layer formed on a bottom surface of the doped laser crystal with a
35 downwardly facing substantially cylindrical concave outer surface. The concentrator may include edge cladding layers formed on the side surfaces of the doped laser crystal. Each cylindrical surface preferably defines a respective optical line focus, with one optical line focus preferably being located above and the other below the laser pump cavity apparatus.

[0006] The laser pump cavity apparatus is preferably pumped with one or more laser diode arrays to provide a source
40 of pumping energy in a direction substantially transverse to the laser beam axis. The cylindrical surfaces preferably have hyperbolic or quasi-hyperbolic cylindrical shape and may be in thermal contact with a pair of cold plates to absorb heat from the two major faces of the slab-like lasing region.

[0007] In one specific embodiment of the laser pump cavity apparatus, the edge cladding layers are made of a material that has a lower thermal conductivity than the material used for the top and bottom cladding layers, thereby
45 maintaining a one-dimensional heat flow condition from the active region of the laser device through the top and bottom cladding layers and into the cold plates. For use in a ytterbium doped yttrium aluminum garnet (Yb: YAG) laser, edge cladding layers are preferably made of undoped YAG material and the top and bottom cladding layers are preferably made of sapphire.

[0008] The foregoing and additional features and advantages of this invention will become further apparent from the
50 detailed description and accompanying drawing figures that follow. In the figures and written description, numerals indicate the various features of the invention, like numerals referring to like features, throughout for the drawing figures and the written description.

DRAWINGS

55 **[0009]** Fig. 1 is a schematic illustration showing an isometric view of one preferred embodiment of a slab laser pump cavity apparatus with integral concentrator. Laser diode arrays and rays of pump light at the left side of the pump cavity are not shown in order to preserve clarity.

[0010] Fig. 2 is a plan view schematic illustration of the slab laser pump cavity apparatus of Fig 1.

[0011] Fig. 3 is a plan view schematic illustration of a slab laser pump cavity apparatus with integral concentrator designed for low f/number pumping, in accordance with another embodiment of the present invention.

[0012] Fig. 4 is a plan view schematic illustration of the slab laser pump cavity apparatus of Fig 1, showing one method of laser light guiding within the active lasing region.

[0013] Fig. 5 is a plan view simplified schematic illustration of an alternate embodiment of a slab laser pump cavity apparatus with thermally insulating edge cladding applied to the active lasing region prior to applying the top and bottom cladding layers.

[0014] Fig. 6 is a plan view simplified schematic illustration of another alternate embodiment of a slab laser pump cavity apparatus with thermally insulating edge cladding applied to the composite concentrator structure.

DETAILED DESCRIPTION

[0015] Fig. 1 is a schematic illustration showing an isometric view of a preferred embodiment of a slab laser pump cavity apparatus with integral concentrator. This embodiment consists of an edge-pumped configuration which employs a slab-shaped laser pump cavity 10 preferably constructed by diffusion bonding an undoped cladding layer such as sapphire 14 around a doped laser crystal active lasing region such as YAG 16, made of a high-aspect ratio slab, which has been doped with an active ion, such as ytterbium. The cladding layer 14 concentrator has a top cladding layer 46 with a concave, upwardly facing outer cylindrical surface 18, a bottom cladding layer 48 having a concave, downwardly facing outer cylindrical surface 18 and a pair of edge cladding layers 50. The active lasing region 16 preferably has a rectangular cross-section and is pumped by laser diode arrays 26.

[0016] The disclosed embodiment preferably uses pumping in directions transverse to the laser beam axis 12, i.e., edge-pumping or side-pumping, although it could also be used with other pumping methods. Edge-pumping implies that pumping is accomplished from a narrow side (edge) of the slab, and not from a wide face of a slab, such as a top or bottom side. At least the top and bottom cladding layers 46,48 are preferably made of undoped sapphire, which is of dissimilar crystal type from the doped laser crystal active lasing region 16, which is preferably Yb:YAG.

[0017] The cylindrical outer surfaces 18 on the top and bottom cladding layers 46,48 of the undoped cladding layer 14 are preferably aligned longitudinally with the laser axis 12 and designed with a concave hyperboloid or near-hyperboloid shape to more uniformly distribute the transverse pump light within the active region 16. Each cylindrical surface 18 has its line focus 20 outside the laser pump cavity 10, as shown in Fig. 1, one above and the other below the laser pump cavity 10. The cylindrical outer surfaces 18 are preferably coated to ensure high reflectivity at the pump wavelength. The cylindrical surfaces 18 are preferably covered with a compliant thermal interface material 22 and each cold plate 24 preferably has a cylindrical 45 surface placed adjacent to the thermal interface 22 which closely conforms to the shape of cylindrical surface 18, thereby facilitating thermal flow from the active region 15 to the cold plates 24. Heat is extracted from the doped laser crystal slab active lasing region 16 by conduction through the undoped cladding layer 14 and through the thermal interface 22 to the cold plate 24. The thermal interface 22 is preferably made of gold or indium metal foil and the cold plate 24 of an aluminum or copper alloy.

The pump light is emitted by the laser diode arrays 26, available commercially, which preferably have integral cylindrical microlenses 28 that act to collimate the pump light from each diode bar a direction normal to the emitting surface. The collimated pump light from each laser diode array 26 is then focused by a large cylindrical lens 30 so that the converging rays of pump light 32, after being refracted at an entrance surface of the pump cavity 34, are directed toward the line foci of the cylindrical surfaces 20. The entrance surface of the laser pump cavity 34 is coated with material which has antireflection properties at the pump wavelength, for the predetermined range of incidence angles, to maximize transmission of the pump light into the laser pump cavity 10.

[0018] In the illustrated embodiment, principal rays of pump light 32, which are focused at one of the line foci of cylindrical surfaces 20, are reflected, by the corresponding cylindrical surface 18, toward the other line focus 20, and this reflecting process is repeated with both cylindrical surfaces 18, thus trapping substantially all of the pump light within the laser pump cavity 10 until it is substantially absorbed. Although paraxial rays are not perfectly trapped, the absorption efficiency for paraxial rays over total path length is high. The overall pumping efficiency of the laser pump cavity 10 is therefore very high, and depends on the absorption of the undoped cladding layer 14, the quality of the high reflectivity coatings on the cylindrical surfaces 18, and the quality of the antireflection coatings at the entrance surfaces of the pump cavity 34.

[0019] Fig. 2 is a plan view schematic illustration of a slab laser pump cavity apparatus with improved thermal lensing control, cooling, and fracture strength which uses sapphire (Al_2O_3) in the undoped cladding layer 14 and ytterbium-doped yttrium aluminum garnet (Yb:YAG) as the active lasing region 16. Sapphire has a lower index of refraction, higher thermal conductivity and improved stress fracture strength over undoped YAG. Therefore, use of sapphire brings three improvements to the slab laser pumphead: improved thermal lensing control, cooling and fracture strength. A particular application of this invention may benefit by any or all of these three improvements, and depends on the

specific selection of the active lasing region 16 medium and the cladding layer 14 material.

[0020] For implementations requiring low f/number pumping, it may be advantageous to shape and/or coat the entrance surface(s) at the side edges of the pump cavity 34 to maximize transmission and avoid critical angle limitations. Fig. 3 is a plan view schematic illustration of a slab laser pump cavity apparatus with integral concentrator designed for low f/number pumping, in accordance with another embodiment of the present invention. In this aspect the cladding layer 14 is preferably made of sapphire, which is of dissimilar crystal type from the doped laser crystal active lasing region 16, which is preferably Yb:YAG. This embodiment, instead of one entrance surface of the pump cavity 34 on each side. The precise angle of the entrance surface of the pump cavity 34 is selected according to the application and is based on a tradeoff between pumping efficiency and suppression of lateral parasitic lasing modes. The lateral parasitic lasing modes can reduce the stored energy in a Q-switched application or compete with the desired lasing process along the laser beam axis 12 in continuous or long-pulse applications.

[0021] The designer can shift the distribution of absorbed pump light toward the center of the slab by slightly under-shooting the line foci 20, which is accomplished by placing the line focus of each laser diode array pump 38 in the region between the cylindrical surface 18 and the line focus 20 corresponding to that cylindrical surface 18.

[0022] In the disclosed embodiment, use of a cladding material with lower index of refraction results in total internal reflection of rays within the laser beam that are incident on the cladded surface of the active lasing region 16 which have an angle of incidence greater than a critical angle. These reflected laser beam rays are guided within the active lasing region 16, thereby minimizing the effects of the laser light being spread due to distributed thermal lensing or diffraction along the length of the slab. Without light guiding, the thermal lensing and free space diffraction within the integrating slab structure would cause the laser beam to spread and eventually exit from the active lasing region 16 would not be amplified.

[0023] Use of a cladding material with a higher thermal conductivity lowers the operating temperature of the active lasing region 16 medium, thereby increasing the laser emission cross section (gain) and improving the extraction efficiency.

[0024] Use of a cladding material having a higher stress fracture strength allows use of shorter slabs with increased pump power per unit length. This presumes that the active lasing region 16 receives its tensile stress from the cladding region 14 and that the limiting parameter is the surface tensile strength of the cladding material. Reducing the required slab length improves laser performance by reducing the linear loss within the slab segments and the Fresnel losses at the interfaces between slab segments, if multiple slab segments are required due to crystal growth limitations. Reducing the number of slab segments also lowers cost.

[0025] The properties of sapphire, including a lower index of refraction, higher thermal conductivity and improved stress fracture strength over a conventional YAG material, bring significant improvements to the disclosed slab laser pump cavity devices over alternative devices made entirely of YAG. For example, the index of refraction for YAG, at 1 μ m wavelength and 300 K temperature, is approximately 1.819 while the index of refraction for sapphire is 1.755.

[0026] In order to achieve total internal reflection, laser light should propagate within the active lasing region 16 at angles of incidence greater than the critical angle. For the YAG/sapphire index of refraction ratio, the critical angle to achieve total internal reflection is given as:

$$c = \arcsin (1.755/1.819) = 74.76$$

[0027] Therefore, laser light may be guided through the active lasing region 16 at angles of incidence between 90 (i.e., along beam axis 12) and 74.76 .

[0028] Fig. 4 is a plan view schematic illustration of one method of guiding laser light through a slab laser pump cavity apparatus total internal reflection, for improved thermal lensing control. In this method the laser light is constrained by bouncing off the top and bottom surfaces of the active lasing region 16, following a zig-zag optical path through the active lasing region 16, so that every part of the beam sees the same optical path length through the active lasing region 16.

[0029] The concept of a slab laser geometry with a zig-zag optical path confined in the slab by total internal reflection was first proposed by Martin and Chernoch, US Patent No. 3,633, 126, issued in 1972. In conventional embodiments of the zigzag slab concept, the large faces of the slab responsible for guiding the laser beam by total internal reflection are exposed to the environment and, in some embodiments, to cooling fluids. Scratches and erosion of these exposed surfaces result in optical degradation which adversely affects the beam quality and lifetime of the laser. In the present embodiment of the invention, these surfaces are protected by the cladding layers and optical degradation due to scratches and erosion will not occur.

[0030] The operating temperature of the laser is a function of the ultimate heatsink temperature, the physical shape of the various materials between the active lasing region 16 of the slab and the heatsink, the thermal conductivities of these materials, and the contact thermal conductivities at the interfaces between these materials.

TABLE

PARAMETER	UNITS	IN YAG	IN SAPPHIRE
refractive index, n at $1.03 \mu\text{m}$, λ	-	1.819	$n_o = 1.755$ $n_e = 1.747$
thermal conductivity, K	W/cm $\cdot$ K	0.10	0.35 $\parallel$ c-axis 0.33 c-axis
thermal expansion coefficient, α	($\times 10^{-6}$) K $^{-1}$	6.9 isotropic	6.8 $\parallel$ c-axis 5.4 $\perp$ c-axis
thermal shock parameter, R	W/cm	7.9	100

[0031] As can be seen from the Table, where all values are given at temperature of 300K degrees, the thermal conductivity of sapphire (approximately 0.34 W/cmK) is three times as high as that for YAG (0.10 W/cmK). Therefore, the temperature drop across the sapphire cladding layer 14 is approximately three times smaller than that across a similarly sized YAG cladding layer 14 for a the same thermal load. For ytterbium and most rare earth lasing species, reducing the temperature of operation increases the stimulated emission cross section of the active lasing region 16. This lowers the saturation fluence of the active lasing region 16 medium, making it easier to extract the stored energy for Q-switched systems without damaging either the optical coatings at the exit surfaces or the bulk lasing material. At room temperature, the cross section of Yb:YAG changes by approximately 8% for a 10 C change in the operating temperature of the active lasing region 16 medium.

[0032] With the availability of high brightness diode pump arrays, the minimum length of the laser active lasing region 16 medium along the lasing axis mostly depends on the fracture strength of the medium. A shorter laser medium is advantageous because it reduces the linear optical loss associated with absorption of the laser light in the medium and, in embodiments where the desired length of the slab exceeds the growth limits of the laser crystal, it also reduces the number of required slab segments and the attendant Fresnel loss at the interfaces.

[0033] The properties of the diffusion bonded slab laser pump cavity devices depend on the fracture strength of the overall structure and not just the fracture strength of the active lasing region 16. Diffusion bonding passivates the interface surface and inhibits both the formation and propagation of surface microcracks that are responsible for catastrophic fracture of the active lasing region 16 medium. Cladding the active Yb:YAG region with sapphire, in addition to passivating the interface surface, also reduces tensile stress near the surface of the Yb:YAG active lasing region 16 during steady state lasing. The tensile stress reduction near the surface of the Yb:YAG region occurs because the coefficient of thermal expansion for sapphire is $< 6.8 \times 10^{-6}$ K $^{-1}$, depending on crystal axis orientation, which is less than that for other conventional cladding materials such as YAG, where $= 6.9 \times 10^{-6}$ K $^{-1}$. Thus the cladding layer 14 tries to maintain a compressive force on the YAG side of the interface. This behavior is analogous to the property of tempered glass in which the glass surface is kept in compression, thereby resisting thermal stress fracture with high temperature gradients across the glass wall.

[0034] Because the thermal expansion coefficient for sapphire is a function of crystal axis orientation, the designer has the freedom to select an optimum crystal axis orientation that will control the stress transfer at the interface and/or reduce the stress birefringence effects within the active lasing region 16.

[0035] The diffusion bond between the active lasing region 16 and the cladding layer 14 transmits stress from the active lasing region 16 to the cladding layer 14, putting the surface of the cladding layer 14 under tension. The fracture toughness and thermal conductivity of the cladding layer 14 are therefore important determinants of the overall thermal fracture strength of the monolithic slab laser pump cavity. Because sapphire has a higher fracture toughness and thermal conductivity than YAG, its thermal shock parameter (100 W/cm) is more than an order of magnitude higher than YAG (7.9 W/cm). The sapphire cladding layer 14, therefore, can handle much higher thermal loads without stress fracture than the YAG cladding layer 14 disclosed in the referenced copending application.

[0036] In some applications it is important to maintain a one-dimensional heat flow within the active lasing region 16. By orienting the linear polarization of the laser beam either perpendicular or parallel to the heat flow direction, depolarization within the slab, due to thermal stress birefringence, can be minimized. As is conventionally known, thermally insulating the edge of a laser slab approximates the ideal one-dimensional heat flow condition. In the present invention this can be accomplished by first diffusion bonding each side surface of the active lasing region 16 with an edge cladding layer 50 that has lower thermal conductivity than the top and bottom cladding layers 46, 48 used at the top and bottom surfaces of the doped laser crystal 16.

[0037] Fig. 5 is a plan view simplified schematic illustration of an alternate embodiment of a slab laser pump cavity apparatus with thermally insulating edge cladding applied to the active lasing region prior to applying the top and bottom

cladding layers. In this embodiment, undoped YAG could be used for the edge cladding layer 50 and sapphire could be used for the top and bottom cladding layers 46, 48. Edge claddings may also be composed of doped material in order to suppress amplified spontaneous emission and/or parasitic lasing.

[0038] Edge cladding can also be diffusion bonded to the composite concentrator structure either before or after the top and bottom cladding layers have been diffusion bonded.

Fig. 6 is a plan view simplified schematic illustration of alternate embodiment of a slab laser pump cavity apparatus with thermally insulating edge cladding applied to the composite concentrator structure. An added advantage of this embodiment is improved heat flow that more nearly approximates the desired one dimensional condition near the edges of the active lasing medium. In this embodiment, undoped YAG could be used for the edge cladding layer 50 and sapphire could be used for the top and bottom cladding layers 46, 48.

[0039] The apparatus aspect of the present invention is believed to be applicable to all types of integrating laser pump cavity devices with integral concentrator such as are used in high power solid-state laser products for industrial and military applications.

[0040] While this invention has been described with reference to its presently preferred embodiment(s), its scope is only limited insofar as defined by the following set of claims and all equivalents thereof.

Claims

1. A laser pump cavity apparatus with integral pump light concentrator, comprising:

a doped solid-state laser medium providing an active lasing region (16) having a top surface (40), a bottom surface (42) and at least two side surfaces (44) surrounding a laser beam axis (12); and
a concentrator having a top cladding layer (46) formed on the top surface of the active laser region (16) and having a first upwardly facing concave cylindrical outer surface (18), and a bottom cladding layer (48) formed on the bottom surface of the active lasing region (16) and having a second downwardly facing concave cylindrical outer surface (18), said first concave cylindrical outer surface (18) defining a first optical line focus (20) located parallel to the laser beam axis (12) and above the laser pump cavity apparatus (10), said second concave cylindrical outer surface (18) defining a second optical line focus (20) located parallel to the laser beam axis (12), and below the laser pump cavity apparatus (10), wherein at least the top (46) and bottom cladding layers (48) of the concentrator are formed of a different material than the doped solid-state laser medium.

2. The laser pump cavity apparatus of claim 1, wherein:

the concentrator material is sapphire, and the doped solid-state laser medium is Yb:YAG.

3. The laser pump cavity apparatus of any preceding claim, wherein:

the concentrator is formed by diffusion bonding the cladding layers (46) and (48) to the active lasing region (16).

4. The laser pump cavity apparatus of any preceding claim, wherein:

at least the top (46) and bottom (48) cladding layers are formed from a material with having a lower index of refraction than the doped laser medium.

5. The laser pump cavity apparatus of any preceding claim, wherein:

at least the top (46) and bottom (48) cladding layers are formed from a material having a higher thermal conductivity than the doped laser medium.

6. The laser pump cavity apparatus of any preceding claim, wherein:

at least the top (46) and bottom (48) cladding layers are formed from a material having a higher stress fracture strength than the doped laser medium.

7. The laser pump cavity apparatus of any preceding claim, further comprising:

a pair of edge cladding layers (50) formed on the two edge surfaces (44) of the active lasing region (16).

8. The laser pump cavity apparatus of claim 7, wherein:

the edge cladding layers (50) are formed from a second cladding material that has a lower thermal conductivity than the cladding material used to form the top (46) and bottom (48) cladding layers, whereby the edge of the active lasing region may be thermally insulated from the top (46) and bottom (48) cladding layers to maintain a one-dimensional heat flow condition through the top (40) and bottom (42) surfaces of the active lasing region (16).

9. The laser pump cavity apparatus of claims 7 or 8, wherein:

the edge cladding layers (50) are made of undoped YAG material and the top (46) and bottom (48) cladding layers are made of sapphire.

10. The laser pump cavity apparatus of any preceding claim, further comprising:

an upper cold plate (24) having a bottom surface (45) in thermal contact with the first upwardly facing concave cylindrical outer surface (18); and
a lower cold plate (24) having an upper surface (45) in thermal contact with the second downwardly facing concave cylindrical outer surface (18).

Patentansprüche

1. Laser-Pumpraumvorrichtung mit integrelem Pumplichtkonzentrator, welche folgendes enthält:

ein dotiertes Festkörper-Lasermedium, das einen aktiven Laserbereich (16) bildet und eine obere Fläche (40), eine untere Fläche (42) und mindestens zwei Seitenflächen (44) aufweist, welche eine Laserstrahlachse (12) umgeben; und

einen Konzentrator mit einer oberen Abdeckschicht (46), welche auf der oberen Fläche des aktiven Laserbereiches (16) gebildet ist und eine erste, nach aufwärts weisende konkave zylindrische Außenfläche (18) aufweist, sowie mit einer unteren Abdeckschicht (48), die auf der unteren Fläche des aktiven Laserbereiches (16) gebildet ist und die eine zweite, nach abwärts weisende konkave zylindrische Außenfläche (18) aufweist, wobei die erste konkave zylindrische Außenfläche (18) eine erste optische Brennpunktlinie (20) definiert, die parallel zu der Laserstrahlachse (12) ausgerichtet und oberhalb der Laser-Pumpraumvorrichtung (10) gelegen ist, wobei die zweite konkave zylindrische Außenfläche (18) eine zweite optische Brennpunktlinie (20) definiert, die parallel zu der Laserstrahlachse (12) ausgerichtet und unterhalb der Laser-Pumpraumvorrichtung (10) gelegen ist und wobei mindestens die obere Abdeckschicht (46) und die untere Abdeckschicht (48) des Konzentrators aus einem Material gebildet sind, das von demjenigen des dotierten Feststoff-Lasermedium verschieden ist.

2. Laser-Pumpraumvorrichtung nach Anspruch 1, bei welcher das Konzentratormaterial Saphir ist und das dotierte Feststoff-Lasermedium Yb:YAG ist.

3. Laser-Pumpraumvorrichtung nach irgendeinem vorhergehenden Anspruch, bei welchem der Konzentrator durch Anfügen der Abdeckschichten (46 und 48) an den aktiven Laserbereich (16) durch Diffusionsverbindung gebildet ist.

4. Laser-Pumpraumvorrichtung nach irgendeinem vorhergehenden Anspruch, bei welcher mindestens die obere Abdeckschicht (46) und die untere Abdeckschicht (48) aus einem Material gebildet sind, das einen niedrigeren Brechungsindex hat, als das dotierte Lasermedium.

5. Laser-Pumpraumvorrichtung nach irgendeinem vorhergehenden Anspruch, bei welcher mindestens die obere Abdeckschicht (46) und die untere Abdeckschicht (48) aus einem Material hergestellt sind, das eine höhere thermische Leitfähigkeit hat, als das dotierte Lasermedium.

6. Laser-Pumpraumvorrichtung nach irgendeinem vorhergehenden Anspruch, bei welcher mindestens die obere Abdeckschicht (46) und die untere Abdeckschicht (48) aus einem Material gefertigt sind, das eine höhere Bruchspannungsfestigkeit als das dotierte Lasermedium hat.

7. Laser-Pumpraumvorrichtung nach irgendeinem vorhergehenden Anspruch, welches weiter folgendes enthält:

ein Paar von Randabdeckungsschichten (50), die auf den beiden Randflächen (44) des aktiven Lasermediums (16) gebildet sind.

8. Laser-Pumpraumvorrichtung nach Anspruch 7, bei welcher die Randabdeckschichten (50) aus einem zweiten Abdeckmaterial gefertigt sind, das eine niedrigere thermische Leitfähigkeit als das Abdeckmaterial hat, das zur Bildung der oberen Abdeckschicht (46) und der unteren Abdeckschicht (48) verwendet ist, derart, daß der Rand des aktiven Lasermediums thermisch von der oberen Abdeckschicht (46) und der unteren Abdeckschicht (48) isoliert werden kann, um die Bedingung eines eindimensionalen Wärmestroms durch die obere Fläche (40) und die untere Fläche (42) des aktiven Laserbereiches (16) aufrechtzuerhalten.

9. Laser-Pumpraumvorrichtung nach Anspruch 7 oder 8, bei welcher die Randabdeckschichten (50) aus undotiertem YAG-Material gefertigt sind und die obere Abdeckschicht (46) sowie die untere Abdeckschicht (48) aus Saphir gefertigt sind.

10. Laser-Pumpraumvorrichtung nach irgendeinem vorhergehenden Anspruch, welche weiter folgendes enthält:

eine obere kalte Platte (24) mit einer unteren Fläche (45) in thermischem Kontakt mit der ersten, nach aufwärts weisenden konkaven zylindrischen Außenfläche (18); und

eine untere kalte Platte (24), welche eine obere Fläche (45) in thermischem Kontakt mit der zweiten, nach abwärts weisenden konkaven zylindrischen Außenfläche (18) aufweist.

Revendications

1. Appareil à cavité de pompage laser comportant un concentrateur de lumière de pompage intégré, comprenant :

un milieu laser à l'état solide dopé fournissant une région laser active (16) ayant une surface supérieure (40), une surface inférieure (42) et au moins deux surfaces latérales (44) entourant l'axe (12) d'un faisceau laser ; et un concentrateur ayant une couche de placage supérieure (46) formée sur la surface supérieure de la région laser active (16) et ayant une première surface extérieure cylindrique concave tournée vers le haut (18) et une couche de placage inférieure (48) formée sur la surface inférieure de la région laser active (16) et ayant une seconde surface extérieure cylindrique concave tournée vers le bas (18), ladite première surface extérieure cylindrique concave (18) définissant un premier foyer linéaire optique (20) situé parallèlement à l'axe (12) du faisceau laser et au-dessus de l'appareil à cavité de pompage laser (10), ladite seconde surface extérieure cylindrique concave (18) définissant un second foyer linéaire optique (20) situé parallèlement à l'axe (12) du faisceau laser, et en dessous de l'appareil à cavité de pompage laser (10), dans lequel au moins les couches de placage supérieure (46) et inférieure (48) du concentrateur sont formées d'un matériau différent du milieu laser à l'état solide dopé.

2. Appareil à cavité de pompage laser selon la revendication 1, dans lequel :

le matériau du concentrateur est le saphir, et le milieu laser à l'état solide dopé est le Yb:YAG.

3. Appareil à cavité de pompage laser selon l'une quelconque des revendications précédentes, dans lequel :

le concentrateur est formé par liaison par diffusion des couches de placage (46) et (48) à la région laser active (16).

4. Appareil à cavité de pompage laser selon l'une quelconque des revendications précédentes, dans lequel :

au moins les couches de placage supérieure (46) et inférieure (48) sont formées d'un matériau ayant un indice

de réfraction inférieur à celui du milieu laser dopé.

5. Appareil à cavité de pompage laser selon l'une quelconque des revendications précédentes, dans lequel :

5 au moins les couches de placage supérieure (46) et inférieure (48) sont formées d'un matériau ayant une conductivité thermique plus élevée que celle du milieu laser dopé.

6. Appareil à cavité de pompage laser selon l'une quelconque des revendications précédentes, dans lequel :

10 au moins les couches de placage supérieure (46) et inférieure (48) sont formées d'un matériau ayant une résistance à la rupture sous contrainte plus élevée que celle du milieu laser dopé.

7. Appareil à cavité de pompage laser selon l'une quelconque des revendications précédentes, comprenant en outre :

15 une paire de couches de placage de bord (50) formées sur les deux surfaces de bord (44) de la région laser active (16).

8. Appareil à cavité de pompage laser selon la revendication 7, dans lequel :

20 les couches de placage de bord (50) sont formées d'un second matériau de placage qui présente une conductivité thermique inférieure à celle du matériau de placage utilisé pour former les couches de placage supérieure (46) et inférieure (48), grâce à quoi le bord de la région laser active peut être isolé thermiquement des couches de placage supérieure (46) et inférieure (48) pour maintenir un état de flux thermique monodimensionnel à travers les surfaces supérieure (40) et inférieure (42) de la région laser active (16).

9. Appareil à cavité de pompage laser selon les revendications 7 ou 8, dans lequel :

30 les couches de placage de bord (50) sont faites d'un matériau YAG non dopé et les couches de placage supérieure (46) et inférieure (48) sont faites de saphir.

10. Appareil à cavité de pompage laser selon l'une quelconque des revendications précédentes, comprenant en outre :

35 une plaque froide supérieure (24) ayant une surface inférieure (45) en contact thermique avec la première surface extérieure cylindrique concave tournée vers le haut (18) ; et
une plaque froide inférieure (24) ayant une surface supérieure (45) en contact thermique avec la seconde surface extérieure cylindrique concave tournée vers le bas (18).

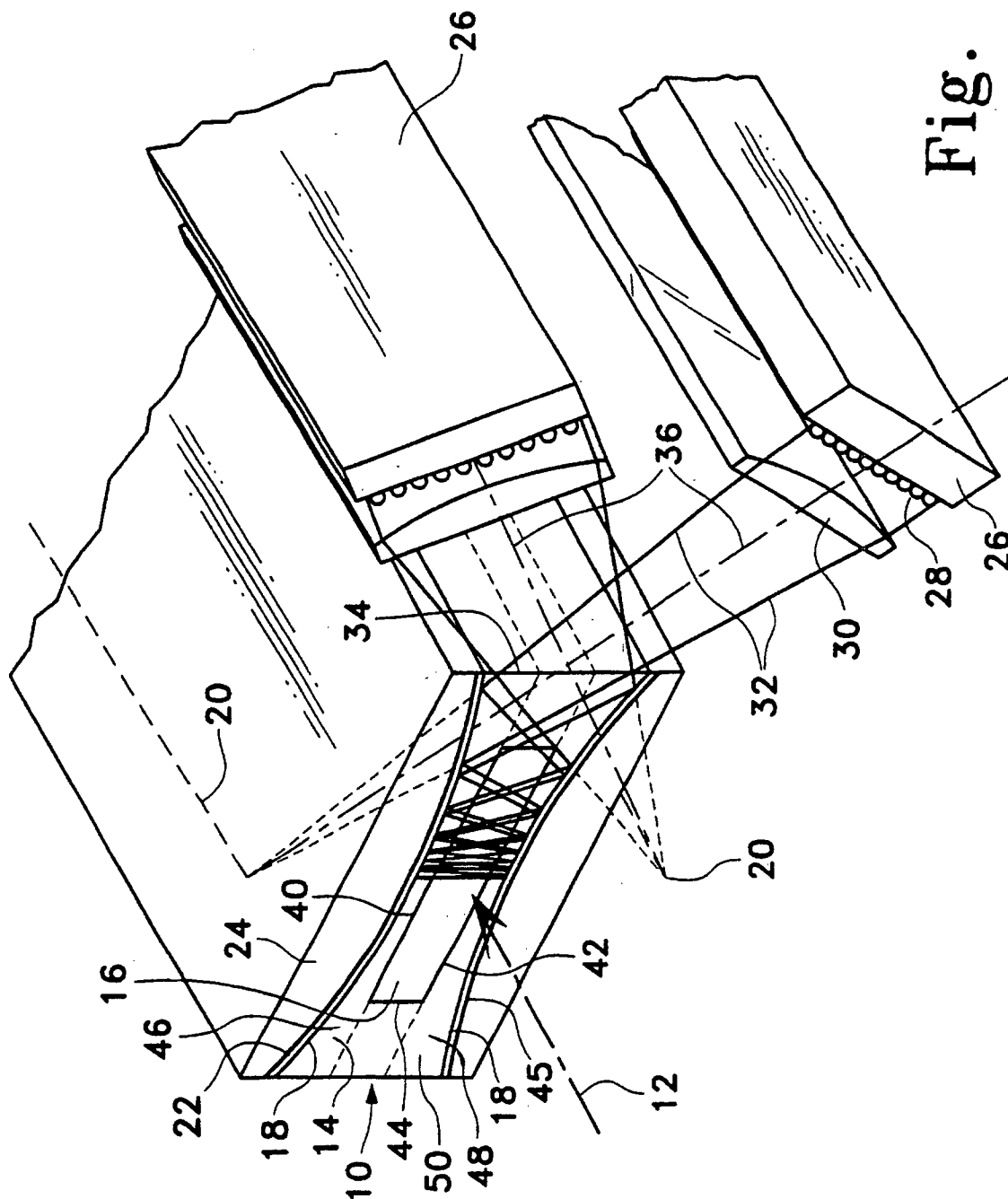


Fig. 1

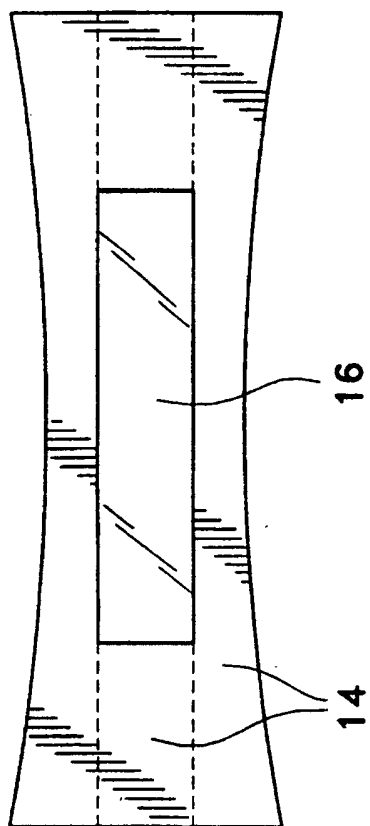


Fig. 2

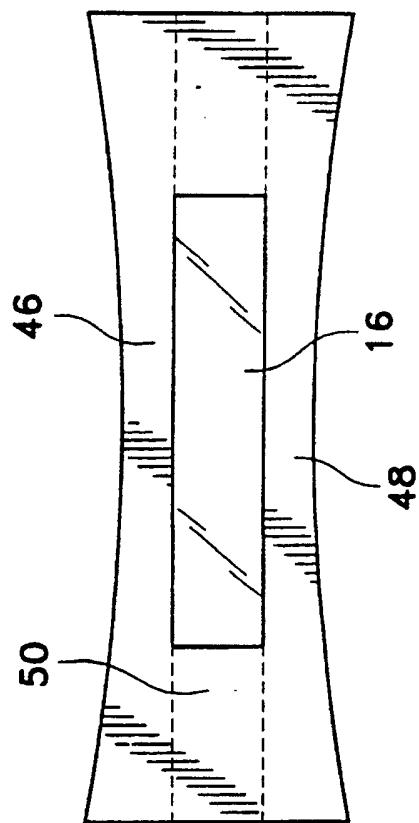


Fig. 5

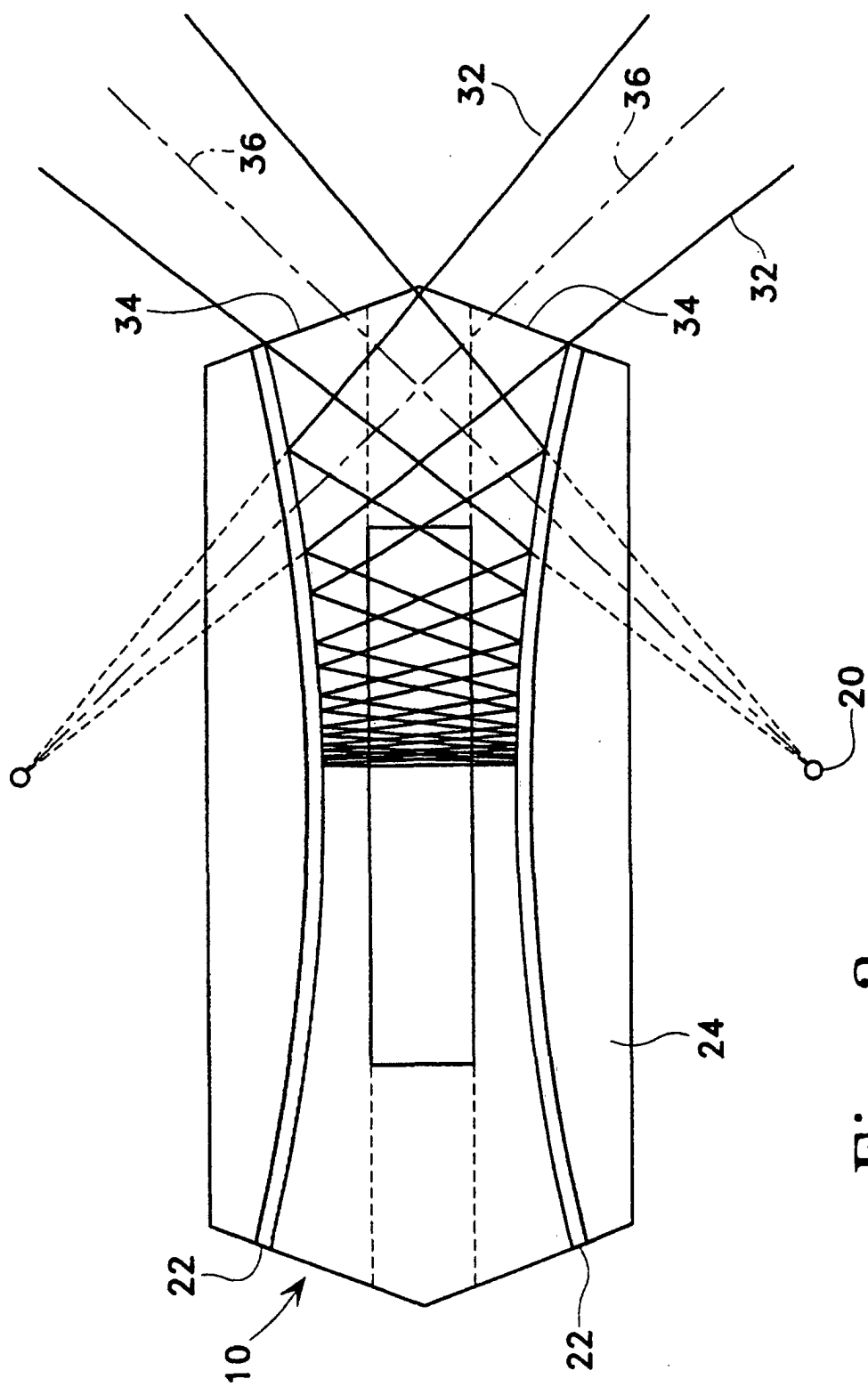


Fig. 3

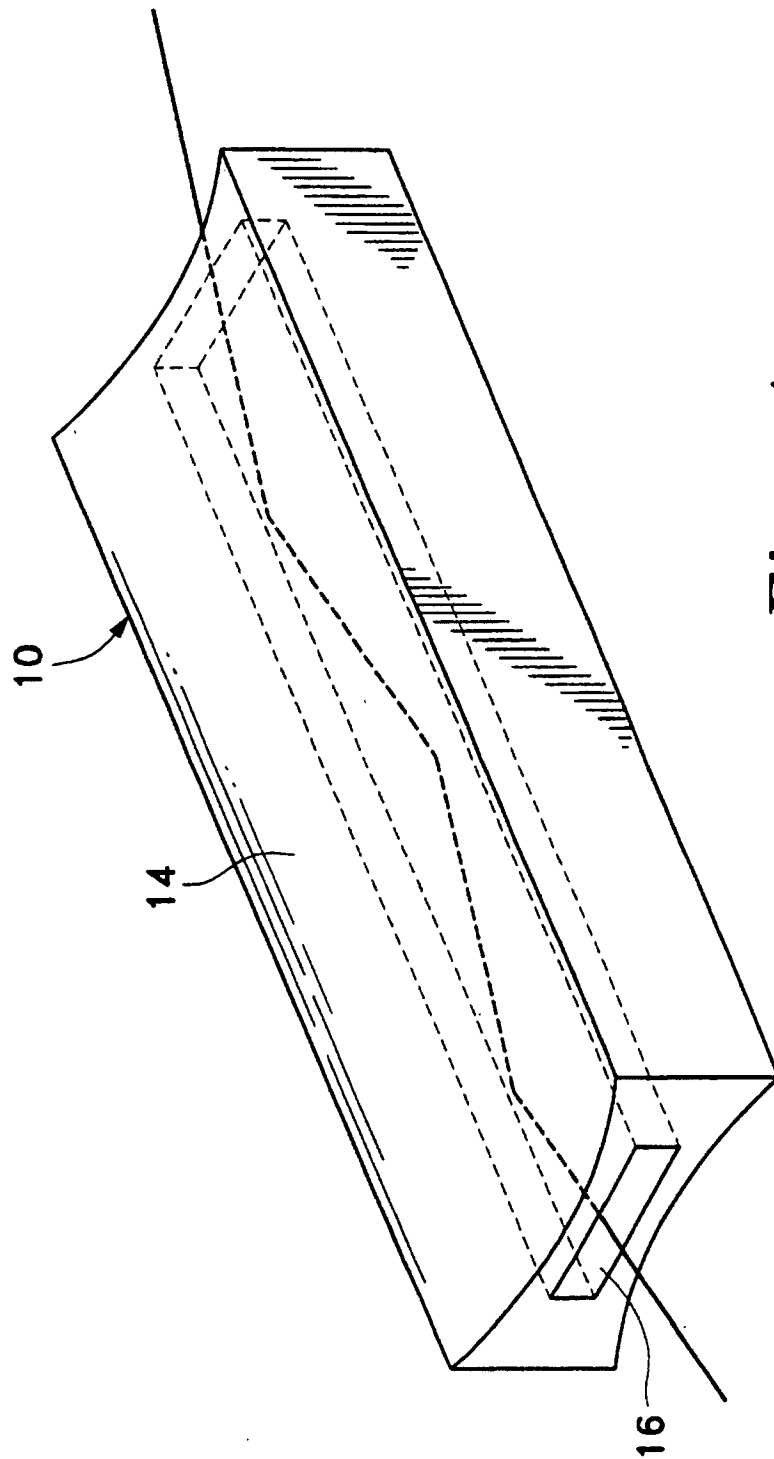


Fig. 4